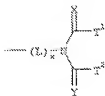


AMENDMENTS TO THE CLAIMS

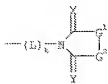
1. (Previously Presented) A polymer comprising a phenolic monomeric unit wherein the H atom of the hydroxy group of the phenolic monomeric unit is replaced by a N-imide group Q having the structure



wherein L is a linking group, wherein k is 0 or 1, wherein L is covalently bound to the O atom of the polymer when k is 1, or wherein the N atom of the N-imide group is covalently bound to the O atom of the polymer when k is 0, wherein X or Y are independently selected from O or S, and wherein T¹ and T² represent a terminal group.

2. (Original) A polymer according to claim 1 wherein the terminal groups T¹ and T² are independently selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, or wherein T¹ and T² together with the N-imide group represent the necessary atoms to form a cyclic structure, or wherein T¹ and T² represent the following structures -L¹-R¹ and -L²-R², wherein L¹ and L² represent independently a linking group, wherein R¹ and R² are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, halogen, -CN, or -NO₂, or therein two groups selected from each L¹, L², R¹ and R² together represent the necessary atoms to form a cyclic structure.

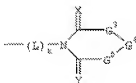
3. (Withdrawn) A polymer according to claim 1 wherein the N-imide group Q has the following formula



wherein G¹ and G² are independently selected from O, S, NR³ or CR⁴R⁵, with the limitation that G¹ is not O or S when G² is O and that G¹ is not O or S when G² is NR³, wherein R⁴ and

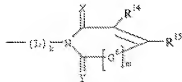
R^5 are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group or $-L^3-R^6$, wherein L^3 is a linking group, wherein R^3 and R^6 are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, or wherein two groups selected from each R^3 , R^4 , R^5 , R^6 and L^3 together represent the necessary atoms to form a cyclic structure.

4. (Withdrawn) A polymer according to claim 1 wherein the N-imide group Q has the following formula



wherein G^3 to G^5 are independently selected from O, S, NR^7 or CR^8R^9 , with the limitation that at least one group, selected from G^3 to G^5 , is CR^8R^9 and that two neighboring groups, selected from G^3 to G^5 , are not represented by O and S, by O and NR^7 , by S and NR^7 or by O and O, or wherein G^4 is a linking group, wherein R^8 and R^9 are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group or $-L^4-L^{10}$, wherein L^4 is a linking group, wherein R^7 and R^{10} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaralkyl or heteroaralkyl group, or wherein two groups selected from each R^7 , R^8 , R^9 , R^{10} and L^4 together represent the necessary atoms to form a cyclic structure.

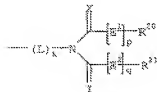
5. (Currently Amended) A polymer according to claim 1 wherein the N-imide group Q has the following formula



wherein G^6 is a group selected from O, S, NR^{11} or $CR^{12}R^{13}$, wherein m is 0 or 1, wherein R^{12} to R^{15} are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group or $-L^5-R^{16}$,

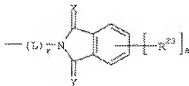
wherein L^5 is a linking group, wherein R^{11} and R^{16} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, or wherein two groups selected from each R^{11} , R^{12} , R^{13} , R^{14} , R^{15} , R^{16} and $[[L^5]]$ together represent the necessary atoms to form a cyclic structure.

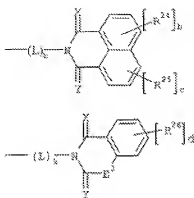
6. (Withdrawn) A polymer according to claim 1 wherein the N-imide group Q has the following formula



wherein E^1 and E^2 are independently selected from O, S, NR^{17} or $CR^{18}R^{19}$, wherein p and q are independently 0 or 1, wherein R^{18} to R^{21} are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group or $-L^6-R^{22}$, wherein L^6 is a linking group, wherein R^{17} and R^{22} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group.

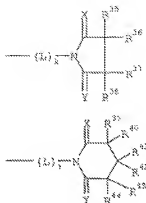
7. (Withdrawn) A polymer according to claim 1 wherein the N-imide group Q has one of the following formula:





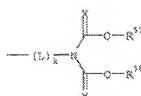
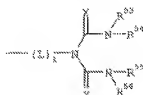
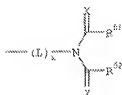
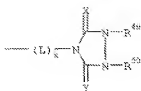
wherein each R^{23} to R^{26} are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, halogen, $-SO_2-NH-R^{27}$, $-NH-SO_2-R^{30}$, $-CO-NR^{27}-R^{28}$, $-NR^{27}-CO-R^{30}$, $-NR^{27}-CO-NR^{28}-R^{29}$, $-NR^{27}-CS-NR^{28}-R^{29}$, $-NR^{27}-CO-O-R^{28}$, $-O-CO-NR^{27}-R^{28}$, $-O-CO-R^{30}$, $-CO-O-R^{27}$, $-CO-R^{27}$, $-SO_2-R^{27}$, $-O-SO_2-R^{30}$, $-SO_2-R^{27}$, $-SO-R^{30}$, $-P(=O)(-O-R^{27})(-O-R^{28})$, $-O-P(=O)(-O-R^{27})(-O-R^{28})$, $-NR^{27}-R^{28}$, $-O-R^{27}$, $-S-R^{27}$, $-CN$, $-NO_2$, $-N(CO-R^{27})(CO-R^{28})$, $-N$ -phthalimidyl, $-M$ -N-phthalimidyl, or $-M-R^{27}$, wherein M represents a divalent linking group containing 1 to 8 carbon atoms, wherein R^{27} to R^{29} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, wherein R^{30} is selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, wherein a and d are independently 0, 1, 2, 3 or 4, wherein b and c are independently 0, 1, 2 or 3, wherein E^3 is selected from O, S, NR^{31} or $CR^{32}R^{33}$, wherein R^{32} and R^{33} are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, or $-L^7-R^{34}$, wherein L^7 is a linking group, wherein R^{31} and R^{34} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group.

8. (Withdrawn) A polymer according to claim 1 wherein the N-imide group Q has one of the following formula:



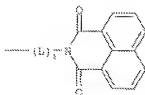
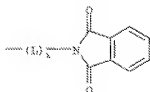
wherein R^{35} to R^{44} are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, halogen, $-\text{SO}_2\text{-NH-R}^{45}$, $-\text{NH-SO}_2\text{-R}^{48}$, $-\text{CO-NR}^{45}\text{-R}^{46}$, $-\text{NR}^{45}\text{-CO-R}^{48}$, $-\text{NR}^{45}\text{-CO-NR}^{46}\text{-R}^{47}$, $-\text{NR}^{45}\text{-CS-NR}^{46}\text{-R}^{47}$, $-\text{NR}^{45}\text{-CO-O-R}^{46}$, $-\text{O-CO-NR}^{45}\text{-R}^{46}$, $-\text{O-CO-R}^{48}$, $-\text{CO-O-R}^{45}$, $-\text{CO-R}^{45}$, $-\text{SO}_3\text{-R}^{45}$, $-\text{O-SO}_2\text{-R}^{48}$, $-\text{SO}_2\text{-R}^{45}$, $-\text{SO-R}^{48}$, $-\text{P(=O)(O-R}^{45})(\text{O-R}^{46})$, $-\text{O-P(=O)(O-R}^{45})(\text{O-R}^{46})$, $-\text{NR}^{45}\text{-R}^{46}$, $-\text{O-R}^{45}$, $-\text{S-R}^{45}$, $-\text{CN}$, $-\text{N}(\text{CO-R}^{45})(\text{CO-R}^{46})$, $-\text{N-phthalimidyl}$, $-\text{M-N-phthalimidyl}$, or $-\text{M-R}^{45}$, wherein M represents a divalent linking group containing 1 to 8 carbon atoms, wherein R^{45} to R^{47} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, and wherein R^{48} is selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group.

9. (Withdrawn) A polymer according to claim 1 wherein the N-imide group Q has one of the following formula:



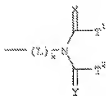
wherein R^{49} to R^{56} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, and wherein R^{57} and R^{58} are independently selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group.

10. (Withdrawn) A polymer according to claim 1 wherein the N-imide group Q has one of the following formula:



11. (Previously Presented) A polymer according to claim 1, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.

12. (Previously Presented) A heat-sensitive lithographic printing plate precursor comprising a support having a hydrophilic surface and an oleophilic coating [[.]] provided on the hydrophilic surface, said coating comprising an infrared light absorbing agent and a polymer comprising a phenolic monomeric unit wherein the H atom of the hydroxy group of the phenolic monomeric unit is replaced by a N-imide group Q having the structure



wherein L is a linking group, wherein k is 0 or 1, wherein L is covalently bound to the O atom of the polymer when k is 1, or wherein the N atom of the N-imide group is covalently bound to the O atom of the polymer when k is 0, wherein X or Y are independently selected from O or S, and wherein T¹ and T² represent a terminal group.

13. (Original) A lithographic printing plate precursor according to claim 12, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

14. (Currently Amended) A lithographic printing plate precursor according to claim 13, wherein said dissolution inhibitor is selected from the group consisting of an organic compound which comprises at least one aromatic group and a hydrogen bonding site,

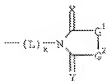
a polymer or surfactant comprising siloxane [[orperfluoroalkyl]] or perfluoroalkyl units, and mixtures thereof.

15. (Canceled)

16. (Previously Presented) A lithographic printing plate precursor according to claim 12, wherein said coating further comprises a latent Brønsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

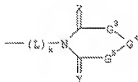
17. (Canceled)

18. (Withdrawn) A polymer according to claim 2 wherein the N-imide group Q has the following formula



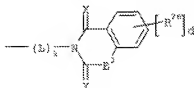
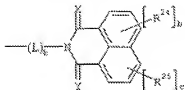
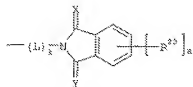
wherein G^1 and G^2 are independently selected from O, S, NR^3 or CR^4R^5 , with the limitation that G^1 is not O or S when G^2 is O and that G^1 is not O or S when G^2 is NR^3 , wherein R^4 and R^5 are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group or $-L^3-R^6$, wherein L^3 is a linking group, wherein R^3 and R^6 are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, or wherein two groups selected from each R^3 , R^4 , R^5 , R^6 and L^3 together represent the necessary atoms to form a cyclic structure.

19. (Withdrawn) A polymer according to claim 2 wherein the N-imide group Q has the following formula



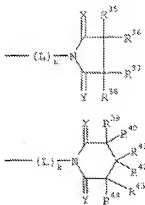
wherein G^3 to G^5 are independently selected from O, S, NR^7 or CR^8R^9 , with the limitation that at least one group, selected from G^3 to G^5 , is CR^8R^9 and that two neighbouring groups, selected from G^3 to G^5 , are not represented by O and S, by O and NR^7 , by S and NR^7 or by O and O, or wherein G^4 is a linking group, wherein R^8 and R^9 are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl,

22. (Withdrawn) A polymer according to claim 2 wherein the N-imide group Q has one of the following formula:



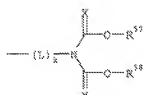
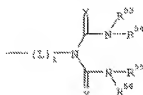
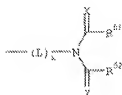
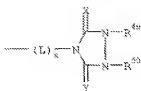
wherein each R^{23} to R^{26} are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, halogen, $-\text{SO}_2\text{-NH-R}^{27}$, $-\text{NH-SO}_2\text{-R}^{28}$, $-\text{CO-NR}^{27}\text{-R}^{28}$, $-\text{NR}^{27}\text{-CO-R}^{30}$, $-\text{NR}^{27}\text{-CO-NR}^{28}\text{-R}^{29}$, $-\text{NR}^{27}\text{-CS-NR}^{28}\text{-R}^{29}$, $-\text{NR}^{27}\text{-CO-O-R}^{28}$, $-\text{O-CO-NR}^{27}\text{-R}^{28}$, $-\text{O-CO-R}^{30}$, $-\text{CO-O-R}^{27}$, $-\text{CO-R}^{27}$, $-\text{SO}_3\text{-R}^{27}$, $-\text{O-SO}_2\text{-R}^{30}$, $-\text{SO}_2\text{-R}^{27}$, $-\text{SO-R}^{30}$, $-\text{P(=O)(-O-R}^{27})(\text{-O-R}^{28})$, $-\text{O-P(=O)(-O-R}^{27})(\text{-O-R}^{28})$, $-\text{NR}^{27}\text{-R}^{28}$, $-\text{O-R}^{27}$, $-\text{S-R}^{27}$, $-\text{CN}$, $-\text{NO}_2$, $-\text{N(CO-R}^{27})(\text{CO-R}^{28})$, $-\text{N-phthalimidyl}$, $-\text{M-N-phthalimidyl}$, or $-\text{M-R}^{27}$, wherein M represents a divalent linking group containing 1 to 8 carbon atoms, wherein R^{27} to R^{29} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, wherein R^{30} is selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, wherein a and d are independently 0, 1, 2, 3 or 4, wherein b and c are independently 0, 1, 2 or 3, wherein E^3 is selected from O, S, NR^{31} or $\text{CR}^{32}\text{R}^{33}$, wherein R^{32} and R^{33} are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, or $-\text{L}^7\text{-R}^{34}$, wherein L^7 is a linking group, wherein R^{31} and R^{34} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group.

23. (Withdrawn) A polymer according to claim 2 wherein the N-imide group Q has one of the following formula:



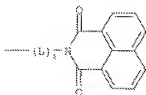
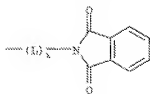
wherein R^{35} to R^{44} are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, halogen, $-\text{SO}_2\text{-NH-R}^{45}$, $-\text{NH-SO}_2\text{-R}^{48}$, $-\text{CO-NR}^{45}\text{-R}^{46}$, $-\text{NR}^{45}\text{-CO-R}^{48}$, $-\text{NR}^{45}\text{-CO-NR}^{46}\text{-R}^{47}$, $-\text{NR}^{45}\text{-CS-NR}^{46}\text{-R}^{47}$, $-\text{NR}^{45}\text{-CO-O-R}^{46}$, $-\text{O-CO-NR}^{45}\text{-R}^{46}$, $-\text{O-CO-R}^{48}$, $-\text{CO-O-R}^{45}$, $-\text{CO-R}^{45}$, $-\text{SO}_3\text{-R}^{45}$, $-\text{O-SO}_2\text{-R}^{48}$, $-\text{SO}_2\text{-R}^{45}$, $-\text{SO-R}^{48}$, $-\text{P(=O)(O-R}^{45})(\text{-O-R}^{46})$, $-\text{O-P(=O)(O-R}^{45})(\text{-O-R}^{46})$, $-\text{NR}^{45}\text{-R}^{46}$, $-\text{O-R}^{45}$, $-\text{S-R}^{45}$, $-\text{CN}$, $-\text{N}(\text{-CO-R}^{45})(\text{-CO-R}^{46})$, $-\text{N-phthalimidyl}$, $-\text{M-N-phthalimidyl}$, or $-\text{M-R}^{45}$, wherein M represents a divalent linking group containing 1 to 8 carbon atoms, wherein R^{45} to R^{47} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, wherein R^{48} is selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group.

24. (Withdrawn) A polymer according to claim 2 wherein the N-imide group Q has one of the following formula:



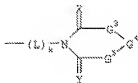
wherein R^{49} to R^{56} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, and wherein R^{57} and R^{58} are independently selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group.

25. (Withdrawn) A polymer according to claim 2 wherein the N-imide group Q has one of the following formula:



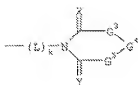
26. (Previously Presented) A heat-sensitive lithographic printing plate precursor according to claim 12, wherein the terminal groups T^1 and T^2 are independently selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, or wherein T^1 and T^2 together with the N-imide group represent the necessary atoms to form a cyclic structure, or wherein T^1 and T^2 represent the following structures $-L^1-R^1$ and $-L^2-R^2$, wherein L^1 and L^2 represent independently a linking group, wherein R^1 and R^2 are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, halogen, -CN, or -NO₂, or therein two groups selected from each L^1 , L^2 , R^1 and R^2 together represent the necessary atoms to form a cyclic structure.

27. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 12, wherein the N-imide group Q has the following formula



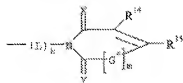
wherein G^3 to G^5 are independently selected from O, S, NR^7 or CR^8R^9 , with the limitation that at least one group, selected from G^3 to G^5 , is CR^8R^9 and that two neighboring groups, selected from G^3 to G^5 , are not represented by O and S, by O and NR^7 , by S and NR^7 or by O and O, or wherein G^4 is a linking group, wherein R^8 and R^9 are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group or $-L^4-L^{10}$, wherein L^4 is a linking group, wherein R^7 and R^{10} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaralkyl or heteroaralkyl group, or wherein two groups selected from each R^7 , R^8 , R^9 , R^{10} and L^4 together represent the necessary atoms to form a cyclic structure.

28. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 12, wherein the N-imide group Q has the following formula



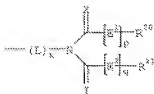
wherein G^3 to G^5 are independently selected from O, S, NR^7 or CR^8R^9 , with the limitation that at least one group, selected from G^3 to G^5 , is CR^8R^9 and that two neighboring groups, selected from G^3 to G^5 , are not represented by O and S, by O and NR^7 , by S and NR^7 or by O and O, or wherein G^4 is a linking group, wherein R^8 and R^9 are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group or $-L^4-L^{10}$, wherein L^4 is a linking group, wherein R^7 and R^{10} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaralkyl, aralkyl or heteroaralkyl group, or wherein two groups selected from each R^7 , R^8 , R^9 , R^{10} and L^4 together represent the necessary atoms to form a cyclic structure.

29. (Previously Presented) A heat-sensitive lithographic printing plate precursor according to claim 12, wherein the N-imide group Q has the following formula



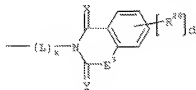
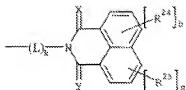
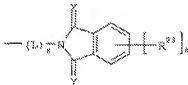
wherein G^6 is a group selected from O, S, NR^{11} or $CR^{12}R^{13}$, wherein m is 0 or 1, wherein R^{12} to R^{15} are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group or $-L^5R^{16}$, wherein L^5 is a linking group, wherein R^{11} and R^{16} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, or wherein two groups selected from each R^{11} , R^{12} , R^{13} , R^{14} , R^{15} , R^{16} and L^5 together represent the necessary atoms to form a cyclic structure.

30. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 12, wherein the N-imide group Q has the following formula



wherein E^1 and E^2 are independently selected from O, S, NR^{17} or $CR^{18}R^{19}$, wherein p and q are independently 0 or 1, wherein R^{18} to R^{21} are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group or $-L^6-R^{22}$, wherein L^6 is a linking group, wherein R^{17} and R^{22} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group.

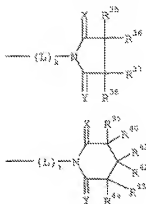
31. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 12, wherein the N-imide group Q has one of the following formula:



wherein each R^{23} to R^{26} are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, halogen, $-SO_2-NH-R^{27}$, $-NH-SO_2-R^{30}$, $-CO-NR^{27}-R^{28}$, $-NR^{27}-CO-R^{30}$, $-NR^{27}-CO-NR^{28}-R^{29}$, $-NR^{27}-CS-NR^{28}-R^{29}$, $-NR^{27}-CO-O-R^{28}$, $-O-CO-NR^{27}-R^{28}$, $-O-CO-R^{30}$, $-CO-O-R^{27}$, $-CO-R^{27}$, $-SO_3-R^{27}$, $-O-SO_2-R^{30}$, $-SO_2-R^{27}$, $-SO-R^{30}$, $-P(=O)(-O-R^{27})(-O-R^{28})$, $-O-P(=O)(-O-R^{27})(-O-R^{28})$, $-NR^{27}-R^{28}$, $-O-R^{27}$, $-S-R^{27}$, $-CN$, $-NO_2$, $-N(-CO-R^{27})(-CO-R^{28})$, $-N$ -phthalimidyl, $-M$ -N-phthalimidyl, or $-M-R^{27}$, wherein M represents a divalent linking group

containing 1 to 8 carbon atoms, wherein R^{27} to R^{29} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, wherein R^{30} is selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, wherein a and d are independently 0, 1, 2, 3 or 4, wherein b and c are independently 0, 1, 2 or 3, wherein E^3 is selected from O, S, NR^{31} or $CR^{32}R^{33}$, wherein R^{32} and R^{33} are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, or $-L^7-R^{34}$, wherein L^7 is a linking group, wherein R^{31} and R^{34} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group.

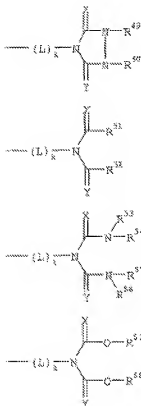
32. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 12, wherein the N-imide group Q has one of the following formula:



wherein R^{35} to R^{44} are independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, halogen, $-SO_2-NH-R^{45}$, $-NH-SO_2-R^{48}$, $-CO-NR^{45}-R^{46}$, $-NR^{45}-CO-R^{48}$, $-NR^{45}-CO-NR^{46}-R^{47}$, $-NR^{45}-CS-NR^{46}-R^{47}$, $-NR^{45}-CO-O-R^{46}$, $-O-CO-NR^{45}-R^{46}$, $-O-CO-R^{48}$, $-CO-O-R^{45}$, $-CO-R^{45}$, $-SO_3-R^{45}$, $-O-SO_2-R^{48}$, $-SO_2-R^{45}$, $-SO-R^{48}$, $-P(=O)(O-R^{45})(O-R^{46})$, $-O-P(=O)(O-R^{45})(O-R^{46})$, $-NR^{45}-R^{46}$, $-O-R^{45}$, $-S-R^{45}$, $-CN$, $-N(CO-R^{45})(CO-R^{46})$, $-N$ -phthalimidyl, $-M$ -N-phthalimidyl, or $-M-R^{45}$, wherein M represents a divalent linking group containing 1 to 8 carbon atoms, wherein R^{45} to R^{47} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl

group, wherein R^{48} is selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group.

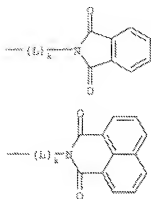
33. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 12, wherein the N-imide group Q has one of the following formula:



wherein R^{49} to R^{56} are independently selected from hydrogen or an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group,

and wherein R^{57} and R^{58} are independently selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group.

34. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 12, wherein the N-imide group Q has one of the following formula:



35. (Previously Presented) A heat-sensitive lithographic printing plate precursor according to claim 26, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

36. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 27, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

37. (Previously Presented) A heat-sensitive lithographic printing plate precursor according to claim 28, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

38. (Previously Presented) A heat-sensitive lithographic printing plate precursor according to claim 29, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

39. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 30, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

40. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 31, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

41. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 32, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

42. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 33, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

43. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 34, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.

44. (Previously Presented) A heat-sensitive lithographic printing plate precursor according to claim 26, wherein said coating further comprises a latent Brønsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

45. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 27, wherein said coating further comprises a latent Brønsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

46. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 28, wherein said coating further comprises a latent Brønsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

47. (Previously Presented) A heat-sensitive lithographic printing plate precursor according to claim 29, wherein said coating further comprises a latent Brønsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

48. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 30, wherein said coating further comprises a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

49. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 31, wherein said coating further comprises a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

50. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 32, wherein said coating further comprises a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

51. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 33, wherein said coating further comprises a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

52. (Withdrawn) A heat-sensitive lithographic printing plate precursor according to claim 34, wherein said coating further comprises a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

This listing of claims replaces all prior versions, and listings, of claims in the application.